



Image

Attorney Docket No.

Patent
015290-502

RCE/2823

THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Helen H. ZHU et al.

Application No.: 09/820,694

Filing Date: March 30, 2001

Title: METHOD OF PLASMA ETCHING SILICON NITRIDE

Group Art Unit: 2823

Examiner: J. J. Maldonado

Confirmation No.: 7374

REQUEST FOR CONTINUED EXAMINATION
TRANSMITTAL LETTER

MAIL STOP RCE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Customer Number 2 1 8 3 9

Sir:

Applicant(s) requests continued examination under 37 C.F.R. § 1.114 and enclose the

☐ \$385.00 (2801) ☒ \$770.00 (1801) fee due under 37 C.F.R. § 1.17(e).

1. ☐ A. Applicant(s) requests that any previously unentered after final amendments not be entered.
Continued examination is requested based on the enclosed documents identified in item 2 below.

☒ B. Applicant(s) previously submitted the following documents for which continued examination is requested:

☒ Consider the amendment(s)/reply under 37 C.F.R. § 1.116 previously filed on
February 17, 2004

☐ Consider the arguments in the Appeal Brief or Reply Brief previously filed on

☐ Other:

2. The following documents are enclosed with this submission:

☒ Amendment/Reply.

☐ Affidavit(s)/Declaration(s).

☐ Information Disclosure Statement (IDS).

☒ A Petition for Extension of Time.

☒ Other: REQUEST FOR INTERVIEW

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3. ☐ Small entity status is hereby claimed.
☐ No additional claim fee is required.
☒ The fee is calculated below on the basis of the highest number of claims already paid for in this application prior to this submission:

CLAIMS					
	No. of Claims	Highest No. of Claims Thus Paid For	Extra Claims	Rate	Fee
Basic Application Fee (1001)					\$ 770.00
Total Claims	24	MINUS 23 =	1	x \$18.00 (1202) =	\$ 18.00
Independent Claims	3	MINUS 3 =	0	x \$86.00 (1201) =	\$ 0.00
If Amendment adds multiple dependent claims, add \$290.00 (1203)					
Total Fee					\$ 788.00
<input type="checkbox"/> Small Entity Status claimed - subtract 50% of Total Amendment Fee					\$ 0.00
TOTAL FEE DUE					\$ 788.00

4. ☐ A check in the amount of _____ is enclosed for the fee due.
5. ☒ Charge \$ 788.00 to Deposit Account No. 02-4800 for the fee due.
6. ☐ Applicant(s) requests suspension of action by the Office until at least _____, which does not exceed three months from the filing of this RCE, in accordance with 37 C.F.R. § 1.103(c). The required fee under 37 C.F.R. § 1.17(i) is enclosed.

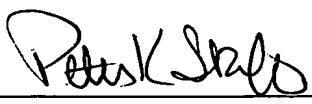
The Director is hereby authorized to charge any appropriate fees under 37 C.F.R. §§ 1.16, 1.17 and 1.21 that may be required by this paper, and to credit any overpayment, to Deposit Account No. 02-4800. This paper is submitted in duplicate.

Respectfully submitted,

BURNS, DOANE, SWECKER & MATHIS, L.L.P.

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Filed: March 19, 2004

By 
Peter K. Skiff
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Patent
Attorney's Docket No. 015290-502

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of)	MAIL STOP: RCE
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Helen H. ZHU et al.)	Group Art Unit: 2823
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Application No.: 09/820,694)	Examiner: J. J. Maldonado
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For: METHOD OF PLASMA ETCHING)	
SILICON NITRIDE)	

AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Further to entry of the February 17, 2004 Amendment as requested in the Request for Continued Examination filed herewith, please amend the above-identified application as follows: